

Interference Search History Print out

MT

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	2	(semiconductor near substrate and via near hole and electrode and photosensitive near resin).CLM.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	OFF	2005/08/08 16:22